	PCT Applicant's Guide - Volume II - National Cha	pter - US Annex US.II, pag				
	,	•				
FORM PTO-1390 (REV. 13-2000)	U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE	ATTORNEY'S DOCKET NUMBER				
	MITTAL LETTER TO THE UNITED STATES	MCA-464				
DESIGNATED/ELECTED OFFICE (DO/EO/US)		U.S APPLICATION NO. (If known, see 37 CFR 15				
	CERNING A FILING UNDER 35 U.S.C. 371	10/009744				
INTERNATION	AL APPLICATION NO. INTERNATIONAL FILING DATE	PRIORITY DATE CLAIMED				
PCT/USOO,		4 June 1999				
HYDROPHOBI	NTION C AND HYDROPHILIC MEMBRANES TO VENT TRAPPED	GASES IN A PLATING CELL				
APPLICANT(S)	FOR DO/EO/US David W. Stockbower					
Applicant herewi	th submits to the United States Designated/Elected Office (DO/EO/US)	the following items and other information				
1 [V] This is a	FIRST submission of items concerning a filing under 35 U.S.C. 371.					
	SECOND or SUBSEQUENT submission of items concerning a filing	under 3511 S.C. 371				
_						
3. [A] This is at items (5)	express request to begin national examination procedures (35 U.S.C. 2, (6), (9) and (21) indicated below.	3/1(1)). The submission must include				
	as been elected by the expiration of 19 months from the priority date (Article 31).				
	the International Application as filed (35 U.S.C. 371(c)(2))					
_	is attached hereto (required only if not communicated by the Internation	mai Bureau).				
-	has been communicated by the International Bureau. is not required, as the application was filed in the United States Received	ing Office (BOJIS)				
	sh language translation of the International Application as filed (35 U.S.	-				
a. D	is attached hereto.	i.e. 37 (c)(2)).				
iН	has been previously submitted under 35 U.S.C. 154(d)(4).					
7. X Amendm	ents to the claims of the International Aplication under PCT Article 19	(35 U.S.C. 371(c)(3))				
a 🔲	are attached hereto (required only if not communicated by the Internat	ional Bureau).				
ь. 🔲	have been communicated by the International Bureau.					
с. 🔲	have not been made; however, the time limit for making such amendment	ents has NOT expired.				
d. 🛛	have not been made and will not be made.					
8. 🔲 An Engli	sh language translation of the amendments to the claims under PCT An	ticle 19 (35 U.S.C. 371 (c)(3)).				
9. An oath o	or declaration of the inventor(s) (35 U.S.C. 371(c)(4)).					
 An English lanugage translation of the annexes of the International Preliminary Examination Report under PCT Article 36 (35 U.S.C. 371(c)(5)). 						
Items 11 to 2	below concern document(s) or information included:					
11. 🔲 An Info	ermation Disclosure Statement under 37 CFR 1.97 and 1.98.					
12. An ass	gnment document for recording. A separate cover sheet in compliance	with 37 CFR 3.28 and 3.31 is included.				
13. A FIRS	A FIRST preliminary amendment.					
14. 🔲 `A SEC	A SECOND or SUBSEQUENT preliminary amendment.					
15. A subs	A substitute specification.					
16. A chan	A change of power of attorney and/or address letter.					
17. A comp	uter-readable form of the sequence listing in accordance with PCT Ru	le 13ter.2 and 35 U.S.C. 1.821 - 1.825.				
18. A secon	ed copy of the published international application under 35 U.S.C. 154	(d)(4).				
19. A seco	nd copy of the English language translation of the international applica	tion under 35 U.S.C. 154(d)(4).				
20. X Other is	ems or information:					
2. 0	opy of the International Preliminary Examin opy of the International Search Report; and opy of Form PCT/IB/308.					

Annex US.II, page 2 PCT Applicant's Guide – Volume II – National Chapter – US

U.S. APPLICATION NO. GLADO	ي الرواقة الموالم	DEFERNATIONAL APPLICATION NO.	PCT/US00/1497	76	ATTORNEYS DOO	CKET NUMBER	
	ing fees are submitted:			CAL		PTO USE ONLY	
BASIC NATIONAL	FEE (37 CFR 1.492 (a)	(1) - (5)):		_			
Neither internation nor international se and International S	nal preliminary examina earch fee (37 CFR 1.445 earch Report not prepar						
International prelin USPTO but Interna	ninary examination fee o ational Search Report pr	\$890.00					
International prelim but international se	ninary examination fee (arch fee (37 CFR 1.445)	(37 CFR 1.482) not paid to (a)(2)) paid to USPTO	USPTO \$740.00				
but all claims did n	ninary examination fee (ot satisfy provisions of I						
International prelin	ninary examination fee ((37 CFR 1.482) paid to US	PTO				
ENTE	Hed provisions of PC1 A	Article 33(1)-(4)BASIC FEE AMO	\$100.00	<u> </u>		1	
				\$	100.00	l	
months from the earl	iest claimed priority dat	or declaration later than te (37 CFR 1.492(e)).	20 🗓 30	s	130.00		
CLAIMS	NUMBER FILED	NUMBER EXTRA	RATE	S			
Tetal claims	10 -20 =	0	x \$18.00	s	0		
Independent claims	4 -3 =	1	x \$84.00	S	84.00		
MULTIPLE DEPENI	DENT CLAIM(S) (if ap		+ \$280.00	S	0		
Applicant claim	s small entity status. Se	DF ABOVE CALCU e 37 CFR 1.27. The fees	LATIONS =	S	314.00		
are reduced by I	/2.		+	s	_		
	0 00 for formishing about	St	BTOTAL =	\$	314.00		
menths from the earl	iest claimed priority dat			\$	-		
tad		TOTAL NATIO	NAL FEE =	\$	314.00		
accompanied by an a	enclosed assignment (3 ppropriate cover sheet (3	7 CFR 1.21(h)). The assis 37 CFR 3.28, 3.31). \$40.0		\$	0		
(40) (40)		TOTAL FEES E	NCLOSED =	S	314.00		
And and					int to be efunded:	s	
					charged:	\$	
a. $\boxed{\chi}$ A check in the amount of \$ $\underline{314.00}$ to cover the above fees is enclosed.							
b. Please charge my Deposit Account No. in the amount of \$ to cover the above fees. A duplicate copy of this sheet is enclosed.							
c. A The Commissioner is hereby authorized to charge any additional fees which may be required, or credit any overpayment to Deposit Account No. 14-0930. A duplicate copy of this sheet is enclosed.							
Fees are to be charged to a credit card. WARNING: Information on this form may become public. Credit card information should not be included on this form. Provide credit card information and authorization on PTO-2038.							
		on min rotal. Frontac ci	cont card miornianon	anu au	intorization on	P1O-2038.	
NOTE: Where an appropriate time limit under 37 CFR 1.494 or 1.495 has not been met, a petition to revive (37 CFR 1.137 (a) or (b)) must be filed and granted to restore the application to pending status.							
		to restore the application	a to pending status.	1.			
SEND ALL CORRESPO	NDENCE TO:			1/4	/		
		. Lemack	SIGNATUR	Œ			
		& Lemack	Ke	vin S	S. Lemack		
		Main Street	NAME				
Westboro, MA 01581					2,579		
			REGISTRA	TION N	UMBER		

HYDROPHOBIC AND HYDROPHILIC MEMBRANES TO VENT TRAPPED GASES IN A PLATING CELL

BACKGROUND OF THE INVENTION

In semiconductor manufacturing, a plating tool uses a negatively charged anode (usually a copper anode) to plate a positively charged (cathode) silicon wafer. The anode provides a source of replenishing metal ions. At the cathode, the metal ions are reduced to metal and deposited on the cathode surface. Sulfuric acid and a plating solution flows through a chamber around the anode and is used to dissolve a metal (copper) plate. As fluid flows past the anode, it becomes enriched with metal ions.

During the chemical reaction that dissolves the metal (e.g., copper), hydrogen gas is liberated. In addition, entrapped gases are generally present during start-up. These gases must be vented so that they do not effect the electrical field or the wafer plating uniformity. Indeed, a separate upstream degasser removes most dissolved air from the main fluid flow path. The generated hydrogen gas, if not removed, becomes entrapped in the plating solution as bubbles or microbubbles and may interfere with the plating operation.

It therefore would be desirable to provide a means for venting hydrogen gas and any other trapped gases out of the plating solution before the solution reaches the wafer.

SUMMARY OF THE INVENTION

The problems of the prior art have been overcome by the present invention, which provides a plating anode cup filter design that vents unwanted gases from the plating solution before they exit the cell and reach the wafer. specifically, in a first embodiment of the present invention. in the chamber where the fluid flows into the plating tool cell and contacts the anode, it encounters a hydrophobic membrane and a hydrophilic membrane spaced from the hydrophobic A driving force such as a vacuum applied in the space between the membranes removes unwanted gases therein.

30

` 35

5

10

WO 00/75402 PCT/US00/14976

5

10

1

15

25

30

35

In a second embodiment of the present invention, a single membrane is used that is both hydrophobic and hydrophilic. Preferably the hydrophobic portion of the membrane is located at or near the perimeter of the fluid chamber in the plating tool cell, and gas to be vented is directed toward the hydrophobic portion(s).

BRIEF DESCRIPTION OF THE DRAWINGS

Figure 1 is a cross-sectional view of the anode holder in accordance with the present invention;

Figure 2 is a cross-sectional view of the anode holder in accordance with another embodiment of the present invention;

Figure 3 is a top view of a membrane having hydrophilic and a hydrophobic portions in accordance with one embodiment of the present invention;

Figure 4 is a cross-sectional view of an anode holder using the membrane of Figure 3; and

Figure 5 is a cross-sectional view of still another embodiment of the present invention.

DETAILED DESCRIPTION OF THE INVENTION

Turning now to Figure 1, there is shown an anode for use in semiconductor manufacturing. A plating tool cell 10 is the housing for the anode 50, which is preferably a copper anode, and includes one or more fluid inlets 12. Thus, the plating tool cell 10 serves as an anode holder and as a means for fluid distribution to the substrate being plated, such as a wafer (not shown) which is typically rotating for uniform plating. Preferably the plating tool cell 10 is made of plastic, and includes an optional fluid inlet 12 and a fluid outlet 13.

A fluid plating solution or ion source, such as copper sulfate, is introduced into a chamber defined by the plating tool cell 10 through optional fluid inlet 12, and contacts the anode 50. The resulting reaction between the plating solution and the metal anode generates hydrogen gas. In the embodiment shown, situated in the fluid path is a hydrophobic membrane 14. The hydrophobicity of the membrane 14 inhibits or prevents

10

180

15

1110742 11115

30

35

PCT/US00/14976 WO 00/75402

passage of the fluid. However, the porosity of the hydrophobic membrane 14 is such that gases, generally air and hydrogen, entrapped in the fluid are able to pass through the hydrophobic membrane 14 easily. A second membrane 15 is positioned downstream of the first membrane (in the direction away from the anode 50). The second membrane 15 is spaced from the first membrane 14, and is hydrophilic. Once the hydrophilic membrane 15 is wetted, it does not allow the passage of gases through it. Accordingly, most or all of the gases remain in the gap 16 between the two membranes. The gap 16 can be filled with a open mesh type separation material, and may be 1/16 to 1/4 inch wide, on average. A driving force such as a vacuum source in communication with the gap 16 with suitable plumbing draws off the gases, thereby preventing them from contacting the wafer and causing defects. Alternatively, high velocity air can be used to create a vacuum by the venturi effect to draw Figure 2 shows another embodiment where the off the gases. gases are vented in gap 16 by creating a high spot 23 in the gap 16 mechanically. The high spot 23 is a portion of the gap 16 that is wider, from membrane 14 to membrane 15, than the total average width of the gap 16. The air tends to collect in the high spot 23 and vent naturally, or can be assisted with a vacuum or high velocity air pressure. The high spot 23 also can be created by bowing the membrane with external fluid pressure, leaving high spots during processing.

Figure 3 illustrates another embodiment of the present invention. In this embodiment, the membrane 14' is patterned such that only a portion 28 thereof is hydrophobic. Conventional techniques to render portions of the membrane hydrophobic well known to those skilled in the art can be used. Preferably, the hydrophobic portion(s) are located at or near the perimeter of the cell 10, and the fluid flow is directed towards the perimeter, as shown in Figure 4.

Figure 5 illustrates another embodiment of the present invention, where a high spot 23 is created and a small hydrophobic membrane patch 15' is used in a vertical orientation. The hydrophobic membrane 15 is optional, and a

5

bowed hydrophilic membrane 14 is positioned to create a high spot 23 as in the embodiment of Figure 2. The air trapped in gap 16 vents naturally through hydrophobic patch 15' without the use of an external driving force such as a vacuum.

The removal of bubbles from the plating solution prior to their reaching the wafer contributes to lower plating defects on the wafer.

<u>35</u>

<u>5</u>

10

What is claimed is:

- An anode plating cell, comprising:
 - an anode;
- a housing for said anode, said housing having a fluid inlet and a fluid outlet;
- a hydrophobic membrane in said housing downstream of said anode:
- a hydrophilic membrane in said housing downstream of and spaced from said hydrophobic membrane by a gap;

whereby gases entrapped in said fluid pass through said hydrophobic membrane into said gap and are prevented from passing through said hydrophilic membrane.

- The anode plating cell of claim 1, further comprising a driving force for removing said entrapped gases from said gap.
- The anode plating cell of claim 2, wherein said driving force is a vacuum.
- 4. The anode plating cell of claim 1, wherein said anode comprises copper.
 - 5. An anode plating cell, comprising:
- an anode;
- a housing for said anode, said housing having a fluid inlet and a fluid outlet;
- a membrane in said housing downstream of said anode, said membrane having a hydrophobic portion permeable to said fluid and to gases entrapped in said fluid, and a hydrophilic portion permeable to said fluid but not to said gases.
- 6. The anode plating cell of claim 5, further comprising a driving force for removing said entrapped gases from said housing.
- 7. The anode plating cell of claim 6, wherein said driving force is a vacuum.
- 8. The anode plating cell of claim 5, wherein said anode comprises copper.
- 9. A method of removing gases entrapped in a plating solution from an anode plating cell, comprising:

providing an anode in said cell;

5

10

providing a hydrophobic membrane in said cell downstream of said anode:

providing a hydrophilic membrane in said cell spaced from and downstream of said hydrophobic membrane;

circulating plating solution in said anode plating cell to contact said plating solution with said anode;

causing gases entrapped in said plating solution to pass through said hydrophobic membrane but not through said hydrophilic membrane; and

removing said gases from said cell.

10. A method of removing gases entrapped in a plating solution from an anode plating cell, comprising:

providing an anode in said cell;

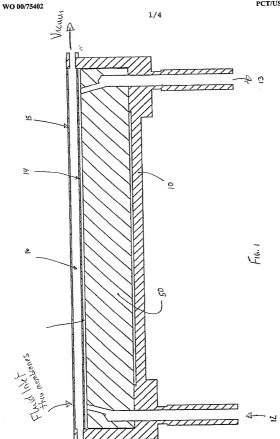
circulating a plating solution in said cell;

causing said plating solution to contact said anode;

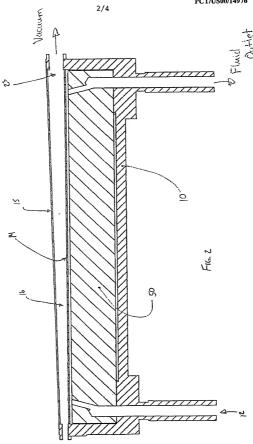
providing a membrane in said cell downstream of said anode, said membrane having a hydrophobic portion permeable to said plating solution and to entrapped gases in said plating solution, and a hydrophilic portion permeable to said plating solution but not to gases entrapped in said plating solution;

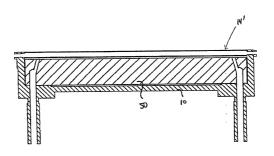
causing gases entrapped in said plating solution to pass through said hydrophobic portion of said membrane but not through said hydrophilic portion; and

removing said gases from said cell.

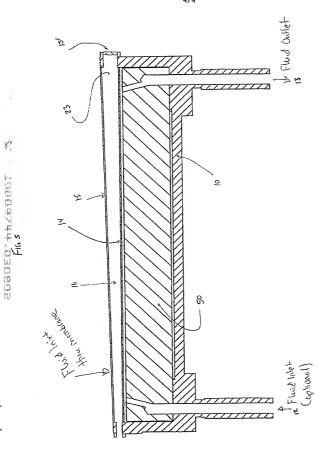








F16.4



PTO/SB/01 (10-00) Approved for use through 10/31/2002. OMB 0651-0032

Approved or use influgin 103 1/20/2. OMB 063 1-0032
U.S. Patent and Tredemark Office; DEPARTMENT OF COMMERCE OF Under the Paperwork Reduction Act of 1995, no persons are required to respond to a collection of information unless it contains a valid OMB control number.

DECLARATION FOR UTILITY OR DESIGN PATENT APPLICATION (37 CFR 1.63)

Declaration
Submitted
with Initial
Filing

OR Declaration
Submitted after Initial
Filing (surcharge
(37 CFR 1.16 (e))
required)

spond to a collection of information unless it contains a valid OMB control number.					
Attorney Docket Number		MCA-464			
First Named Inventor		David W. Stockbower			
COMPLETE IF KNOWN					
Application Number		10 / 009,744			
Filing Date		December 4, 2001			
Group Art Unit					
Examiner Name					

	As a below named inventor, i hereby declare triat.							
My residence, mailing address, and citizenship are as stated below next to my name.								
l believe I am the original, first and sole inventor (if only one name is listed below) or an original, first and joint inventor (if plural names are listed below) of the subject matter which is claimed and for which a palent is sought on the invention entitled:								
HYDROPHOBIC AND HYDROPHILIC MEMBRANES TO VENT TRAPPED GASES IN A PLATING CELL								
	(Title of the Invention)							
the specification of which is attached hereto								
OR		ae United St	ates Application I	dumber or PCT	International			
was filed on (MM/DD/YYYY)	May 31, 200		ates Application i					
Application Number Dom /1000				(i	f applicable).			
·· [FCI/usu		mended on (MM/DD/YY)	,					
I hereby state that I have reviewed amended by any amendment spe-	d and understand the o cifically referred to above	ontents of the above iden re.	tified specification	n, including the	claims, as			
I acknowledge the duty to disclose in-part applications, material inform PCT international filing date of the	e information which is n nation which became a continuation-in-part ap	naterial to patentability as vailable between the filin plication.	defined in 37 CF g date of the prior	R 1.56, includir application an	ng for continuation- d the national or			
In hereby claim foreign pnority benefits under 35 U.S.C. 119(a)-(d) or 365(b) of any foreign application(s) for patent or inventor's certificate, or 365(a) of any PCT international application which designated at least one country other than the United States of America, listed below and have also identified below, by checking the box, any foreign application for patent or inventor's certificate, or any PCT international application having a filing date before that of the application on which priority claimed.								
America, listed below and have	also identified below.	by checking the box, a	ny foreign applic	ation for paten	nt or inventor's			
America, listed below and have	also identified below.	by checking the box, a	ny foreign applic he application on	ation for paten which priority is	nt or inventor's			
America, listed below and have certificate, or any PCT internations Prior Foreign Application	also identified below, al application having a	by checking the box, a filing date before that of the Foreign Filing Date	ny foreign applic he application on Priority	ation for paten which priority is Certified Co	t or inventor's claimed. py Attached?			
America, listed below and have certificate, or any PCT intermation: Prior Foreign Application Number(s)	also identified below, al application having a Country	by checking the box, a filling date before that of the Foreign Filling Date (MM/DD/YYYY)	ny foreign application on Priority Not Claimed	ation for paten which priority is Certified Co YES	t or inventor's sclaimed.			
America, listed below and have certificate, or any PCT internations Prior Foreign Application Number(s) Additional foreign application	also identified below, al application having a Country Country . numbers are listed on a	by checking the box, a filing date before that of it for eight of the (MM/DD/YYYY)	ny foreign applic he application on Priority Not Claimed	ation for paten which priority is Certified Co YES	t or inventor's sclaimed.			
America, listed below and have certificate, or any PCT internations Prior Foreign Application Number(s) Additional foreign application I hereby claim the benefit under	also identified below, all application having a Country Country numbers are listed on a 35 U.S.C. 119(e) of ar	by checking the box, a filling date before that of the Foreign Filling Date (MM/DD/YYYY) a supplemental priority daily united States provision	ny foreign applic he application on Priority Not Claimed	ation for paten which priority is Certified Co YES	t or inventor's sclaimed.			
America, listed below and have certificate, or any PCT internations Prior Foreign Application Number(s) Additional foreign application	also identified below, all application having a Country Country numbers are listed on a 35 U.S.C. 119(e) of ar	by checking the box, a filing date before that of it for eight of the (MM/DD/YYYY)	ny foreign application on Priority Not Claimed La sheet PTO/SB and application(s) Addition numbers supplem	ation for paten which priority is Certified Co YES	py Attached? NO pplication attached is a specific to the property of the pro			

[Page 1 of 2]

Burden Hour Statement: This form is estimated to take 21 minutes to complete Time will vary depending upon the needs of the individual case. Any comments on the amount of time you are required to complete this form should be sent to the Chief Information Officer, U.S. Patent and Trademark Office, Washington, DC 22231. DN OTS PSEND FEED SR COMPLETED FORMS TO THIS ADDRESS, SEND TO. Assistant Commissioner for Patents, Washington, DC 22231.

PTO/SB/81 (10-00)

Approved for use through 10/31/2002, CMB 0651-0035
U.S. Patent and Trademark Office; U.S. DEPARTMENT OF COMMERCE

U.S. Patent and Trademark Office; U.S. DEPARTMENT OF COMMERCE
Under the Paperwork Reduction Act of 1995, no persons are required to respond to a collection of information unless it display a valid OMB control number.

POWER OF ATTORNEY OR AUTHORIZATION OF AGENT

The state of the state of the state of

Application Number	10/009,744
Filing Date	December 4, 2001
First Named Inventor	David W. Stockhower
Group Art Unit	
Examiner Name	
Attorney Docket Number	MCA-464

I hereby appoint: Practitioners at 0	Customer Number		Place Customer Number Bar Code				
OR			Label here				
Practitioner(s) na	med below:						
Name Registration Number							
Kevin	32,5						
Henry	17,0	29					
L							
as my/our attorney(s) o	r agent(s) to prosecute the applica	tion identified ab	ove, and to transact all				
business in the United	States Patent and Trademark Offic	e connected the	rewith.				
	espondence address for the above- led Customer Number.	identified applic	ation to:				
	led Castomer Number.						
OR							
X Firm or Individual Name							
Address	Nields & Lemack						
Address							
City	Westboro	State	MA Zip 01581				
Country	U.S.A.						
Telephone	(508) 898-1818	Fax	(508) 898-2020				
l am the: ☐ Applicant/Inventor. ☐ Assignee of record of the entire interest. See 37 CFR 3.71.							
Statement under 37 CFR 3.73(b) is enclosed. (Form PTO/SB/96).							
SIGNATURE of Applicant or Assignee of Record							
Name David W. Stockbower							
Signature US/02							
Date	~~~						
NOTE: Signatures of all the inventors or assignees of record of the entire interest or their representative(s) are required. Submit multiple forms if more than one signature is required, see below*.							
	rms are submitted.						

Burden Hour Statement. This form is estimated to take 3 minutes to complete. Time will vary depending upon the needs of the individual case. Any comments on the amount of time you are required to complete this form should be sent to the Chief Information Officer, U.S., Patent and Trademark Office, Washington, DC 2023. D. DN OTS SEND FEES OR COMPLETED FORMS TO THIS ADDRESS SEND TO: Assistant Commissioner for Patents, Washington, DC 2023.

RIDIOZAW BEBER

Please type a plus sign (+) inside the PTO/SB/01 (10-00)
Approved for use through 10/3 1/2002. OMB 0851-0032
U.S. Patent and Trademark Office; U.S. DEPARTMENT OF COMMERCE
Under the Paperwork Reduction Act of 1995, no persons are required to respond to a collection of information unless it contains a valid OMB control number.

DECLARATION — Utility or Design Patent Application

Direct all correspondence to: Customer Number or Bar Code Label OR X Correspondence address below								
Name Kevin S. Lemack								
Address Nields & lemack								
Address	Address 176 E. Main Street							
City	Westboro				State	MA	ZIP 01	581
Country	U.S.A.	-	Telephone	(508)	898-	1818	(508)	898-2020
are believed made are pur	I hereby declare that all statements made herein of my own knowledge are true and that all statements made on information and better are believed to be true; and further that these statements were made with the knowledge that willful false statements and the like so made are punishable by fine or imprisonment, or both, under 18 U.S.C. 1001 and that such willful false statements may jeopardize the validity of the application or any patent issued thereon.							
NAME OF	SOLE OR FIRST INV	ENTOR:	101		A petiti	on has been fi	led for this unsi	gned inventor
Given Name (first and mid	dle [if any]) David	W			Family I		ckbower	
Inventor's Signature	Inventor's 1/18/07							
Residence: C	ity Burlingt	., M	1	State	MA (Country US	Citizenship	US
Mailing Addre	ess 85 Center	Street						
Mailing Addr	ess							
City Bur	lington	State	MA		ZIP	01803	Country	US
NAME OF SECOND INVENTOR: A petition has been filed for this unsigned inventor								
Given Name Family Name (first and middle [if any]) or Surname								
Inventor's Signature Date								
Residence: 0	City			State		Country	Citizenship	
Mailing Address								
Mailing Address								
City State ZIP Country								
Additional inventors are being named on thesupplemental Additional Inventor(s) sheet(s) PTO/SB/02A attached hereto.								